

UNITED STATES DEPARTMENT OF COMMERCE Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231

SERIAL NUMBER	FILING DATE	FIRST NAMED INVENTOR		ATTORNEY DOCKET NO.
08/327,887	10/24/94 Kih		S 9983,30803	
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	VENTH STREET MN 55402-410	5 f	1107	,
_			DATE MAILED:	09/10/95
	rom the examiner in cha ATENTS AND TRADEMA			
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This application has	been examined	Responsive to communication filed on)/ <i>1/95</i>	This action is made fir
shortened statutory pe	erlod for response to this a	ection is set to expire3_ month(s),days from	the date of this letter.
		will cause the application to become aban	doned. 35 U.S.C. 133	
art I THE FOLLOWII	NG ATTACHMENT(8) AF	RE PART OF THIS ACTION:	•	
	erences Cited by Examina			nt Drawing Review, PTO-9
	Cited by Applicant, PTO-1 in How to Effect Drawing (lotice of Informal Patent A	pplication, PTO-152.
	-	onangos, 110-1474 U		··
		7		
. Claims		-7		are pending in the application
Of the abo	ove, claims		are w	ithdrawn from consideration
2. Claims			h	nave been cancelled.
a. Claims				are allowed.
4. Ctalms	<u> </u>			are rejected.
5. Ctalms			are subject to restriction	or election requirement.
7. This application	has been filed with Inform	al drawings under 37 C.F.R. 1.85 which a		
3. Formal drawings	are required in response	to this Office action.		
The corrected or are acceptable are	r substitute drawings have lie; 🗆 not acceptable (see	been received on explanation or Notice of Draftsman's Pa	Under 37 C.F.	.R. 1.84 these drawings 0-948).
). The proposed a examiner; did	dditional or substitute she sapproved by the examin	et(s) of drawings, filed on er (see explanation)	has (have) been 🔲	approved by the
1. The proposed dr	awing correction, filed	has been 🗆 app	proved; disapproved (se	ee explanation).
2. Acknowledgeme	nt is made of the claim for parent application, serial n	r priority under 35 U.S.C. 119. The certified. ; filed on;	led copy has Deen reco	eived not been received
3. Since this applications accordance with	ation apppears to be in co the practice under Ex par	undition for allowance except for formal mate Quayle, 1935 C.D. 11; 453 O.G. 213.	atters, prosecution as to th	e merits is closed in
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Art Unit: 1107

The following is a quotation of the first paragraph of 35 U.S.C. § 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

The specification is objected to under 35 U.S.C. § 112, first paragraph, as the specification as originally filed, does not provide support for the invention as is now claimed. There is no support in the specification and drawings for forming holes of substantially equal depth by removing portions of the second insulating layer to expose the first metal and conductive layers since the step which exposes the layers does not create holes of the same depth (see Figure 2C). In re claim 7, there is no support in the specification and drawings for a plurality of filled contact holes of different overall depth resulting from the second contact hole filling since as can be seen from figure 2D the holes have a similar depth.

Claims 1, 2, and 7 are rejected under 35 U.S.C. § 112, first paragraph, for the reasons set forth in the objection to the specification.

Claims 1-7 are rejected under 35 U.S.C. § 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

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Art Unit: 1107

In claims 1, lines 7 and 14, and claim 3, lines 7 and 13, the use of "desired" reads on a nebulous mental step conducted prior to the manipulative steps of the claimed invention, hence rendering the present process claims unclear in meaning and scope. If applicant wishes to patent detailed controls over the recited process, they must be positively recited.

In claims 1 and 3, lines 6 and 12, "the whole structure" has no proper antecedent basis. Furthermore it is unclear which structure is being recited. Perhaps the applicant intends "the resultant structure"?

In claim 2, line 1, "methods" should be --method--.

In claim 4, lines 4 and 7, the scope of the claim is rendered unclear by the use of "associated with". In line 6, the use of "second metal" is confusing since it is unclear if the applicant intends the second metal of line 3 or a different metal layer.

The following is a quotation of 35 U.S.C. § 103 which forms the basis for all obviousness rejections set forth in this Office action:

A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Subject matter developed by another person, which qualifies as prior art only under subsection (f) or (g) of section 102 of this title, shall not preclude patentability under this section where the subject matter and the claimed invention were, at the time the invention was made, owned by the same person or subject to an obligation of assignment to the same person.

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Art Unit: 1107

Claims 1-7 are rejected under 35 U.S.C. § 103 as being unpatentable over the admitted prior art in view of Wolf.

The admitted prior art teaches providing a silicon substrate (10); forming a field oxide (3), junction layer (2), and gate electrode (5); forming a first insulating layer (6) over the structure; forming a patterned conductive layer (7) on the first insulating layer; forming a second insulating layer (8) over the first; forming holes in the first and second insulating film to the gate and junction followed by filling the holes with CVD tungsten (9). The admitted prior art doesn't teach filling the first holes with CVD tungsten with and planarizing the first insulating layer before forming the patterned conductor.

Wolf teaches that planarization of an inter-metal dielectric is desirable before forming subsequent metal on the dielectric (page 201-203). It would have been obvious to one of ordinary skill in the art to have planarized the first dielectric layer in the process of the admitted prior art prior to forming the patterned conductor layer for the benefits as taught by Wolf. Wolf further teaches that filling via holes of significantly varying depth is also a problem (page 204-205). Therefore it would have been obvious to one of ordinary skill in the art to have formed the first holes and have filled them just subsequent or prior to planarizing the first dielectric in the process of the admitted art to have avoided holes of significantly varying depth as taught by Wolf.

In re claim 7, alternatively if a planarizing step was not performed, it would have still been obvious to one of ordinary skill in the art to have formed the first holes and have filled Serial Number: 08/327887 -5-

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them just subsequent to forming the first dielectric in the process of the admitted art to have avoided holes of significantly varying depth as taught by Wolf.

Applicant's arguments filed 5/1/95 have been fully considered but they are deemed to be most in light of the new grounds of rejection.

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

Applicant may respond to this office action by facsimile transmission as per 37 CFR 1.6(d) (Also see MPEP 502.01). Applicant is directed to 58 FR 54494 (October 22, 1993) and 1156 Off. Gaz. Pat. Office 61 (November 16, 1993). Also see 37 CFR 1.4(f). The transmission should identify the serial number of the application, art unit 1107 and the name of the examiner in charge of the application as indicated below. The facsimile numbers for group 1100 are (703)305-3599 and (703)305-3600.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to examiner Thomas Bilodeau whose telephone number is (703) 308-1090.

Any inquiry of a general nature or relating to the status of the application should be directed to the Group Receptionist whose telephone number is (703) 308-0661.

GEUHGO FOURSON PATENT EXAMINER GROUP 1100

ilodeau

August 31, 1995